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Substitute for form 1449/PTO				Complete if Known		
				Application Number	10/576,282-Conf. #1949	
11	VEORMATION	I DI	SCLOSURE	Filing Date	April 19, 2006	
S	TATEMENT E	3Y /	APPLICANT	First Named Inventor	Rainer Papp	
				Art Unit	1626	
	(Use as many sheets as necessary)			Examiner Name	J. M. Nolan	
Sheet	1	of	1	Attorney Docket Number	13111-00038-US1	

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Examiner Initials*	Cite No.1	Document Number Number-Kind Code ² (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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Examiner	Date	
Signature	Considered	

*EXAMINED: Initial if elements consistent, whether or not clation in a conformance with MEPD 950. Dure line through clation if not no conformance and not considered include copy of the form when conformations that a spirated. **Populated** upware allowing copy of the form of conformation of spirated. **Populated** upware allowing copy of the form of conformation and under the conformation of the spirate of the spirate or manufact of the plant of the conformation of the spirate of the spirate or manufact of the spirate or the spirate of the spirate or the spirate of the spir